

AND TRADEMARK OFFICE

UNITED STATES DEPARTMENT OF COMMERCE United States Patent and Trademark Office Address: COMMISSIONER OF PATENTS AND TRADEMARKS Washington, D.C. 20231 www.uspto.gov

APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/052,347	01/23/2002	Katsuhide Manabe	P 282475	4113

12/03/2002

F00-219-USdiv3-c

EXAMINER

PILLSBURY WINTHROP, LLP

P.O. BOX 10500 MCLEAN, VA 22102 MULPURI, SAVITRI

ART UNIT

PAPER NUMBER

2812

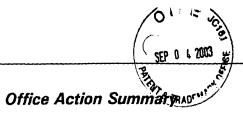
DATE MAILED: 12/03/2002

Please find below and/or attached an Office communication concerning this application or proceeding

RECEIVED

PILLSBURY WINTHROP LLP/VA

DEC 0 5 2002



Application No. 10/052,347

Applicant(s

Manabe et al

Examiner

.

Art Unit 2812



		Javiai Maipan		
	The MAILING DATE of this communication appears	on the cover sheet with the corres	p ndence address	
Period 1	or Reply			
THE N	ORTENED STATUTORY PERIOD FOR REPLY IS SET MAILING DATE OF THIS COMMUNICATION.		1	
mailing - If the p - If NO p - Failure - Any re	ions of time may be available under the provisions of 37 CFR 1.136 (a). In date of this communication. beriod for reply specified above is less than thirty (30) days, a reply within the seriod for reply is specified above, the maximum statutory period will apply to reply within the set or extended period for reply will, by statute, cause the ply received by the Office later than three months after the mailing date of patent term adjustment. See 37 CFR 1.704(b).	the statutory minimum of thirty (30) days will by and will expire SIX (6) MONTHS from the mailin the application to become ABANDONED (35 U.S	s considered timely. ng date of this communication. c.C. § 133).	
Status	patent to management of the transfer		į	
1) 💢	Responsive to communication(s) filed on Sep 17,	2002	·	
2a) □	This action is FINAL . 2b) 💢 This ac	ction is non-final.		
3) 🗆	Since this application is in condition for allowance closed in accordance with the practice under Ex pa		1	
Disposi	tion of Claims			
4) 💢	Claim(s) 1-52 and 119-127	is/are	e pending in the application.	
4	a) Of the above, claim(s)	is/ar	e withdrawn from consideration.	
5) 🗆	Claim(s)		is/are allowed.	
6) 💢	Claim(s) 1-52 and 119-127		is/are rejected.	
7) 🗆	Claim(s)		is/are objected to.	ŕ
8) 🗆	Claims	are subject to restric	ction and/or election requirement.	١.
Applica	ation Papers		l l	
9) 🗆	The specification is objected to by the Examiner.			
10)□	The drawing(s) filed onis/ar	e a) ☐ accepted or b) ☐ objecte	ed to by the Examiner.	
	Applicant may not request that any objection to the		1	
11)	The proposed drawing correction filed on	is: a)□ approved	b) ☐ disapproved by the Examiner.	
	If approved, corrected drawings are required in reply	to this Office action.		
•	The oath or declaration is objected to by the Exam	niner.		
-	under 35 U.S.C. §§ 119 and 120			
	Acknowledgement is made of a claim for foreign	priority under 35 U.S.C. § 119(a))-(d) or (f).	
a) l	☐ All b)☐ Some* c)☐ None of:			
	1. Certified copies of the priority documents ha			
	2. Certified copies of the priority documents ha			
*0	3. Copies of the certified copies of the priority application from the International Burse the attached detailed Office action for a list of the company of the company of the company of the company of the certification.	eau (PCT Rule 17.2(a)).	n this National Stage	
	Acknowledgement is made of a claim for domesti		(e)	
a)[Į.	
15)	Acknowledgement is made of a claim for domesti		i	
Attachn	·	, .,		
~~	otice of References Cited (PTO-892)	4) Interview Summary (PTO-413) Paper	No(s)	
2) 🔲 N	otice of Draftsperson's Patent Drawing Review (PTO-948)	5) Notice of Informal Patent Application	(PTO-152)	
21 "	formation Disclosure Statement(s) (PTO-1449) Pener Nots)	6) Other:		



Art Unit: 2812

DETAILED ACTION

This action is in response to the applicant 's provisions of IDS and amendment to claims filed on 9/17/02

Claim Rejections - 35 USC § 102

The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless -

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 19-36, 119-121 are rejected under 35 U.S.C. 102(b) as being anticipated by Sayyah et al.

Sayyah et al discloses a method of growing GaN or AlGaN on sapphire substrate by vapor phase epitaxy MOCVD, HCVD: Sayyah further discloses growing AlN layer in addition AlGaN and GaN layers, by using silane and with TMG, TMA, and ammonia. Sayyah et al discloses flow rate of silane is 10-1200 SCCM to obtain donor concentration of 9 X 10 ¹⁸/cm ³. Since silicon is shallow donor in GaN, the claimed electron concentration is close to that of disclosed silicon concentration of Prior art in the GaN material. In the prior art the measured silicon concentration was limited by the detect ability limit of the technique used to measure the silicon concentration. Based upon the range of flow rates of silane used in the prior art, it is conceivable that a wide range of silicon concentration spanning more than three decades variation has been achieved in the prior art. Sayyah et al do not explicitly teach conductivity. However, the above dopant silicon concentration in the prior art cover the claimed ranges of conductivity.

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person

Application/Control Number: 10/052347

Art Unit: 2812

having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 37-52, 122-127 are rejected under 35 U.S.C. 103(a) as being unpatentable over Sayyah et al. Sayyah et al does teach individual epitaxial layer of AlGaN, GaN, AlN, but does not teach using one of the layers as buffer layer. It is well known that using one of the above mentioned layers as buffer layer to reduce crystal defects in the active layers used for device.

Applicant's arguments with respect to claims 19-52, 119-127 have been considered but are most in view of the new ground(s) of rejection.

Any inquiry concerning this communication or earlier communications from the examiner should be directed to S. Mulpuri whose telephone number is 703-305-5184. The fax phone number for the organization where this application or proceeding is assigned is 70-308-7722.

Any inquiry of a general nature or relating to the status of this application or proceeding should be directed to the receptionist whose telephone number is 703-308-0956.

SÁVITRI MULPURÍ